

INFORMATION DISCLOSURE STATEMENT

Applicant	:	Suntola et al.
App. No	:	09/855,321
Filed	:	May 14, 2001
For	:	METHOD FOR GROWING THIN FILMS
Examiner	:	David Turocy
Art Unit	:	1762
Confirmation No.	:	9994

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 2 references to be considered by the Examiner. Also enclosed are 2 non-patent literature as listed on the Information Disclosure Statement.

This Information Disclosure Statement is being filed within three months of the filing date, with an RCE or before receipt of a first office action after an RCE and no fee is required.

The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment, to Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated:

December 6, 2001

By:



Andrew N. Merickel
Registration No. 53,317
Attorney of Record
Customer No. 20,995
(415) 954-4114

INFORMATION DISCLOSURE STATEMENT BY APPLICANT	Application No.	09/855,321
	Filing Date	May 14, 2001
	First Named Inventor	Suntola et al.
	Art Unit	1762
(Multiple sheets used when necessary)	Examiner	Daivd Turocy
SHEET 1 OF 1	Attorney Docket No.	ASMMC.013C2

NON PATENT LITERATURE DOCUMENTS			
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ¹
	1	Lei et al., "Real-time observation and optimization of tungsten atomic layer deposition process cycle", American Vacuum Society, 2006, pages 780-789	
	2	Ritala et al., "Atomic Layer Deposition", Handbook of Thin Film Materials, 2002, pages 103-159, Vol. 1	

3183200
120606

Examiner Signature	Date Considered
<p>*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.</p>	

T¹ - Place a check mark in this area when an English language Translation is attached.